What is claimed is:

Τ.	1. A device for use in an imaging system comprising:		
2	a direct conversion detector element configured to convert x-ray		
3	photons into electric current, said direct conversion detector elemen		
4	comprising:		
5	a cathode surface;		
6	an anode surface having a plurality of anode side edges; and		
7	a plurality of detector side surfaces connecting said cathode		
8	surface to said anode surface, said plurality of detector side surfaces each		
9	having a detector depth;		
10	a pixel array assembly positioned on said anode surface, said		
11	pixel array assembly including a plurality of pixel side edges, each of said		
12	plurality of pixel side edges immediately adjacent one of said anode side edges;		
13	a guard ring mounted around said plurality of detector side		
14	surfaces, said guard ring including an upper ring edge, a lower ring edge, and a		
15	ring outer surface including a guard ring height.		
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1	2. A device as in claim 1 further comprising:		
2	a voltage source in communication with said guard ring, sai		
3	voltage source biasing said guard ring with a bias voltage.		
1	3. A device as in claim 1 wherein said upper ring edge and		
2	said lower ring edge are remotely positioned from said cathode surface and sai		
3	anode surface.		
1	4. A device as in claim 1 wherein said ring outer surface is		
2	coplanar with said pixel side edges.		
1	5. A device as in claim 1 wherein said ring outer surface is		
2	coplanar with said plurality of detector side surfaces.		
4	copianal with sale plenancy of detector side surfaces.		

1	6.	A device as in claim 1 wherein said direct conversion
2	detector element con	nprises amorphous selenium.
1	7.	A device as in claim 1 wherein said pixel array assembly
2	comprises a room ter	mperature semiconductor.
1	8.	A device as in claim 1 wherein said direct conversion
2	detector element con	nprises a CdTe detector.
1	9.	A device as in claim 1 wherein guard ring height is 50%
2	or less of said detector depth.	
1	10.	A device as in claim 1 wherein said upper ring edge and
2	said lower ring edg	e are positioned closer to said anode surface than said
3	cathode surface.	
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1	11.	An imaging system comprising:
2	an x-r	ay source;
3	a dete	ector array comprising a plurality of direct conversion
4	detector elements configured to convert x-ray photons into electric current, each	
5	of said plurality of direct conversion detector elements comprising:	
6	a cath	ode surface;
7	an and	ode surface having a plurality of anode side edges; and
8	a plu	rality of detector side surfaces connecting said cathode
9	surface to said ano	de surface, said plurality of detector side surfaces each
10	having a detector depth;	
11	a pixe	el array assembly positioned on said anode surface, said
12	pixel array assembly including a plurality of pixel side edges;	
13	a gua	rd ring mounted around said plurality of detector side
14	surfaces, said guard	ring including an upper ring edge, a lower ring edge, and a
15	ring outer surface	including a guard ring height, said ring outer surface
16	positioned coplanar	with said pixel side edges.

1	12. All imaging system as described in claim 11 wherein		
2	each of said plurality of pixel side edges is positioned immediately adjacent one		
3	of said anode side edges.		
1	12 As investor suctant as in plains 11 footbar assumption of		
1	13. An imaging system as in claim 11 further comprising:		
2	a voltage source in communication with said guard ring, said		
3	voltage source biasing said guard ring with a bias voltage.		
1	14. An imaging system as in claim 11 wherein said upper		
2	ring edge and said lower ring edge are remotely positioned from said cathode		
3	surface and said anode surface.		
1	15. An imaging system as in claim 11, wherein said ring		
2	outer surface is coplanar with said plurality of detector side surfaces.		
1	16. An imaging system as in claim 11 wherein said guard		
2	ring is coated on said plurality of detector side surfaces such that said guard ring		
3	is substantially coplanar with said plurality of detector side surfaces.		
1	17. A method of improving the performance of peripheral		
2	pixel elements positioned on an anode surface of a direct conversion detector		
3	element, the direct conversion detector element having a cathode surface and a		
4	plurality of detector side surfaces, comprising:		
5	applying a guard ring around said plurality of detector side		
6	surfaces, said guard ring applied coplanar to said peripheral pixel elements.		
	10 A made described in claim 17 forther commissions.		
1	18. A method as described in claim 17, further comprising:		
2	applying a bias voltage to said guard ring.		
1	19. A method as described in claim 17, further comprising:		
2	adjusting a guard ring height of said guard ring to maximize the		
3	performance of the peripheral pixel elements.		
1	20. A method as described in claim 17, further comprising:		
_	20. 11 memod as described in claim 17, further comprising.		

- 2 adjusting a guard ring position along a detector depth to
- 3 maximize the performance of the peripheral pixel elements.